

<b>INFORMATION DISCLOSURE STATEMENT BY APPLICANT</b>	Application No.	SHIGA7.047APC
	Filing Date	10/574,073
	First Named Inventor	Watanabe, et al.
	Art Unit	1752
(Multiple sheets used when necessary)	Examiner	Amanda C. Walke
SHEET 1 OF 2	Attorney Docket No.	SHIGA7.047APC

U.S. PATENT DOCUMENTS					
Examiner Initials	Cite No.	Document Number Number - Kind Code (if known) Example: 1,234,567 B1	Publication Date MM-DD-YYYY	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear
/ACW/	1	2003/0082486 A1	05-01-2003	Endo, et al.	
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Examiner Initials	Cite No.	Foreign Patent Document Country Code-Number-Kind Code Example: JP 1234567 A1	Publication Date MM-DD-YYYY	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear	T <sup>1</sup>
/ACW/	7	JP 2003-177537 (Abstract Only)	06-27-2003	FUJI PHOTO FILM CO LTD		√
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	10	JP 09-281696	10-31-1997	HITACHI LTD, HITACHI CHEM CO LTD		√
	11	JP 11-212265	08-06-1999	SUMITOMO CHEM CO LTD		√
	17	JP 2002-202606	07-19-2002	FUJI PHOTO FILM CO LTD		√
	13	JP 2003-241384	08-27-2003	JSR CORP INTERNATL BUSINESS MACH CORP <IBM> JSR MICRO INC		√
	17	JP 2002-236364	08-23-2002	FUJI PHOTO FILM CO LTD		√
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Examiner Signature /Amanda C. Walke/	Date Considered 03/31/2008
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\*Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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/ACW/	19	EP 0562819 A2	09-29-1993	Murata, et al.		

NON PATENT LITERATURE DOCUMENTS			
Examiner Initials	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T <sup>1</sup>

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Examiner Signature     /Amanda C. Walke/	Date Considered     03/31/2008
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